INFORMATION DISCLOSURE
STATEMENT BY APPLICANT
(Not for submission under 37 CFR 1.99)

Application Number Filing Date		10588981		
		2006-08-10	- 10	
First Named Inventor ROI		ERICK BOSWELL		
Art Unit		2821		
Examiner Name	NOT	YET ASSIGNED		
Attorney Docket Number		F146		

				U.S	PATENTS	
≘xaminer nitial*			Kind Code ¹	Issue Date	Name of Patentee or Applicant of cited Document	Pages,Columns,Lines where Relevant Passages or Relevan Figures Appear
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	2	5108535		1992-04-28	ONO ET AL.	
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	1	20070108395				HORSKY ET A	AL.			
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	1	2008094297	wo			2008-08-07	FEI COMPANY			
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	3	2005081940	wo			2005-09-09	FEI COMPANY		-	
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	1	COATH ET AL., C.D.,"A High-Brightness Duoplasmatron Ion Source for Microprobe Secondary-Ion Mass Spectrometry," Rev. Sci. Instrum., American Institute of Physics, February 1995, pgs. 1018-1023, Volume 66(2).								

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Systems, September 2000, pgs. 309-313, Volume 9, Issue 3.

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	JIANG ET AL., X., "Mini RF-Driven Ion Sources for Focused Ion Bean Systems," Review of Scientific Instruments, American Institute of Physics, April 2003, pgs. 2288-2292, Volume 74, No. 4.							
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